

Application/Control No.	Applicant(s)/Patent under Reexamination	
10/540,389	TAKEI ET AL.	
Examiner	Art Unit	
Ling-Siu Choi	1713	

SEARCHED					
Class	Subclass	Date	Examiner		
526	307.5	10/2/2007	LSC		
	317.1				
430	271.1				
	270.1		,		

INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner	
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(INCLUDING SEARCH	STRATEGY	<u> </u>
	DATE	EXMR
West	10/2/2007	LSC
crosslinker-polymer with hydroxy or carboxy- semiconductor-gap fill-antireflective	-	
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